Application No.	Applicant(s)
9/382,708	KIM ET AL.
xaminer	Art Unit
Shengjun Wang	1617
R REMAINS) CLOSED in this other appropriate communicat  17S. This application is subjection.	e correspondence address application. If not included tion will be mailed in due course. THIS ct to withdrawal from issue at the initiativ
een received in Application No. nents have been received in the his communication to file a rep IT of this application.  d. Note the attached EXAMINE eason(s) why the oath or decla e submitted. s Patent Drawing Review ( PTo mendment / Comment or in the c)) should be written on the draw	nis national stage application from the oly complying with the requirements  ER'S AMENDMENT or NOTICE OF aration is deficient.  O-948) attached  Office action of wings in the front (not the back) of end).
6. ☐ Interview Summal Paper No./Mail D 7. ☐ Examiner's Amen	Date
	R REMAINS) CLOSED in this other appropriate communica HTS. This application is subjected MPEP 1308.  The street of

## **DETAILED ACTION**

Applicants' amendments and remarks submitted June 16, 2004 have been fully considered and found persuasive to over come the rejections set forth in the prior office action. Particularly, Zanotti-Russo does not provide sufficient guidance or direction to arrive the polymer herein employed, which provides film-forming properties. As to the teaching of Mori et al. and Yamamoto et al., it is noted that the component d) herein claimed has a hydrophobic group R6 and is structurally and functionally distinct from component disclosed by Mori et al.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shengjun Wang whose telephone number is (571) 272-0632. The examiner can normally be reached on Monday to Friday from 7:00 am to 3:30 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Sreeni Padmanabhan, can be reached on (571) 272-0629. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). SHENGJUNWANG

Shengjun Wang Primary Examiner Art Unit 1617

PHIMARY EXAMINER